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Form 1449 (Modified)

Information Disclosure Statement By Applicant

(Use Several Sheets if Necessary)

Atty Docket No. LAM1P128D1

Applicant: Hemker et al.

Filing Date
July 11, 2003

Application No.:

10/618,289

Group 1765

U.S. Patent Documents

Examiner			U.S. Patent			Sub-	Filing
Initial	No.	No. Patent No. Date Patentee Cla		Class	class	Date	
MA	A1	4,948,458	08/14/90	Ogle			08/14/89
1	A2	4,990,229	02/05/91	Campbell et al.			06/13/89
	A3	5,091,049	02/25/92	Campbell et al.			06/29/90
	A4	5,122,251	06/16/92	Campbell et al.			02/04/91
	A5	5,421,891	06/06/95	Campbell et al.			10/19/92
	A6	5,429,070	07/04/95	Campbell et al.			11/20/92
	A7	5,587,038	12/24/96	Cecchi et al.			06/16/94
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	:A10*	5,021,114	06/04/91	Saito et al.			07/19/88
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	A13*	5,401,350	03/28/95	Patrick et al.			03/08/93
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Examiner /	MAI	thes In	deisen	Date Considered	1/20	205	-

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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Foreign Patent or Published Foreign Patent Application

Examiner		Document	Publication	Country or		Sub-	Trans	slation
Initial	No.	No.	Date	Patent Office	Class	class	Yes	No
MAA	Bl	EP 0838843 A2	04/29/98	EPO				
MA	B2	EP 0821397 A2	01/28/98	EPO				
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MA	B7*	4-329875	11/08/92	ЛР.				

Other Documents

		Other Documents			
Examiner					
Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication			
MH	C1	Japanese Application No. 04094953, filed March 1992, entitled "PLASMA DAMAGE REDUCTION AND PLASMA PROCESSOR, by Minegishi Kazushige, Patent Abstracts of Japan, Vol. 18, No. 33.			
MA	C2	Japanese Application No. 08255259, filed August 1996, entitled "PLASMA DAMAGE REDUCTION AND PLASMA PROCESSOR, by Minegishi Kazushige, Patent Abstracts of Japan, Vol. 18, No. 33.			
M	C3*	Office Action dated March 28, 2001 for U.S. Application No. 09/439,661, entitled "PLASMA PROCESSING SYSTEMS," filed on November 15, 1999, now U.S. Patent No. 6,341,574 B1.			
M	C4*	* Office Action dated June 27, 2001 for U.S. Application No. 09/439,661, entitled "PLASMA PROCESSING SYSTEMS," filed on November 15, 1999, now U.S. Patent No. 6,341,574 B1.			
Examiner	Wall	Date Considered 7/24/2005			

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